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# Combustion Co-synthesis of nano SiC and purified Si<sub>3</sub>N<sub>4</sub> powders by coupling strong and weak exothermic reactions

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Silicon carbide (SiC) powders and silicon nitride (Si<sub>3</sub>N<sub>4</sub>) powders are critical raw materials for advanced ceramic technology and industry. There are two challenges in their synthesis and production: (i) Nano SiC powders due to harsh reaction temperature for phase formation, and (ii) high-purity Si<sub>3</sub>N<sub>4</sub> powders due to difficulties in removing trace oxygen impurities. Combustion synthesis is a cheap, scalable method to synthesize SiC and Si<sub>3</sub>N<sub>4</sub> powders. Yet there are two additional challenges: (iii) Combustion synthesis of SiC requires intense external energy input due to the weak exothermic reaction between Si and C, and (iv) combustion synthesis of Si<sub>3</sub>N<sub>4</sub> requires dilutant to slow down the self-accelerated reaction and fully convert Si to Si<sub>3</sub>N<sub>4</sub> due to strong exothermic reaction between Si and N<sub>2</sub>. Here we reported a new combustion co-synthesis of nano SiC and high-purity Si<sub>3</sub>N<sub>4</sub> powders in one chamber, which addresses all four challenges mentioned above: (i) Nano SiC powders resolved by fast synthesis, (ii) purified pink-grade Si<sub>3</sub>N<sub>4</sub> powders using carbon as efficient high-temperature oxygen getter, (iii) ignited Si-C combustion by strongly exothermic Si-N<sub>2</sub> reaction, and (iv) more controllable Si-N<sub>2</sub> combustion with less dilutant usage and less residue Si. We demonstrated nano  $\beta$ -SiC powders with ~30 nm primary particle size and high-purity pink-colored  $\beta$ -Si<sub>3</sub>N<sub>4</sub> powders with oxygen impurity content down to 0.46 wt%. Our work



not only offers practical solutions to the production of high-quality SiC and Si<sub>3</sub>N<sub>4</sub> powders but also refreshes the design of combustion synthesis with new possibilities and improved controllability.

**Keywords:** Combustion synthesis; SiC; Si<sub>3</sub>N<sub>4</sub>; Nanoparticles; Reaction kinetics.

## 1. Introduction

The semiconductor industry has undergone rapid development in recent years, resulting in a significant increase in demand for high-performance SiC and Si<sub>3</sub>N<sub>4</sub> ceramics. These ceramics are essential components in semiconductor processing equipment.<sup>1-3</sup> SiC semiconductor components require highly reactive, nanoscale SiC powders to achieve superior mechanical and thermal properties.<sup>4-6</sup> In contrast, high thermal conductivity Si<sub>3</sub>N<sub>4</sub> ceramic substrates rely on high-purity, low-oxygen Si<sub>3</sub>N<sub>4</sub> powders to ensure optimal thermal conductivity.<sup>7-9</sup> Currently, a variety of synthesis routes, such as carbothermal reduction, sol-gel processing, combustion synthesis, and high-energy ball milling, have demonstrated the capability to successfully produce ceramic powders.<sup>10</sup> In order to produce SiC and Si<sub>3</sub>N<sub>4</sub> ceramic powders in a scalable and cost-effective manner, it is essential to consider both manufacturing efficiency and overall material performance.<sup>11,12</sup> In this context, combustion synthesis has emerged as one of the most promising approaches for the large-scale and low-cost fabrication of high-quality Si-based ceramic powders.<sup>13,14</sup> However, existing combustion synthesis technologies for SiC and Si<sub>3</sub>N<sub>4</sub> still face critical limitations, highlighting the urgent need for innovation and breakthrough developments.

First, the Si-C reaction system is difficult to sustain in a self-propagating manner due to its low exothermicity ( $\Delta H = -69 \text{ kJ mol}^{-1}$ ) and relatively low adiabatic combustion temperature ( $T_{\text{ad}} = 1860 \text{ }^{\circ}\text{C}$ ).<sup>15,16</sup> Previous studies have demonstrated that combustion synthesis of SiC can be achieved through preheating,<sup>17</sup> chemical activation,<sup>18</sup> or nitrogen-assisted catalysis.<sup>19</sup> For instance, the addition of PTFE significantly enhances reactivity through gas-phase reactions and additional exothermicity.<sup>20</sup> However, these approaches typically involve an excessive thermal input to trigger the reaction, which leads to overly high reaction temperatures and consequently causes significant grain coarsening, making it difficult to obtain sub-100 nm SiC powders. Alternatively, mechanically activated combustion synthesis has been employed to enhance reactivity through high-energy ball milling (HEBM), which promotes the formation of nanocomposite Si/C particles.<sup>21</sup> Yet, the



extended mechanical milling of precursors inevitably introduces significant impurities, thereby limiting the purity of the resulting SiC products.<sup>22,23</sup>

Second, although the Si-N<sub>2</sub> system is a highly exothermic reaction ( $\Delta H = -736 \text{ kJ mol}^{-1}$ ),<sup>15</sup> a large amount of diluents or ammonium salts must be introduced to suppress the reaction temperature in order to prevent the aggregation of molten Si and ensure sufficient nitridation.<sup>24,25</sup> However, such strategies are not without their drawbacks. They result in low net yields and generate corrosive gases, which pose significant environmental concerns.<sup>26</sup> In fact, recent mechanistic studies have shown that the Si-N<sub>2</sub> combustion process follows a vapor-liquid-crystal growth pathway, where the presence of Si<sub>3</sub>N<sub>4</sub> diluents not only moderates the temperature but also accelerates combustion front propagation by promoting nucleation of new Si<sub>3</sub>N<sub>4</sub> crystals.<sup>27</sup> Therefore, both the combustion synthesis routes for SiC and for Si<sub>3</sub>N<sub>4</sub> require further optimization and improvement. To optimize the combustion synthesis processes for both types of powders, the guiding principle is to regulate the structure of the combustion wave. Specifically, the subjecting of the reactant in the combustion wave region to an appropriate high temperature and high-temperature residence time results in process control of nucleation and growth of the simulated powder products.

Based on the above analysis, this study proposes a simple yet practical strategy for the coupled combustion synthesis of the Si-C and Si-N<sub>2</sub> reaction systems. By exploiting the highly exothermic nature of the Si-N<sub>2</sub> reaction as a chemical furnace, the thermal deficit of the weakly exothermic Si-C system can be effectively compensated. Simultaneously, the rapid heat absorption by the Si-C primary reactant system helps to suppress overheating in the Si-N<sub>2</sub> zone. By adjusting the ratio between the Si-N<sub>2</sub>-based chemical furnace and the Si-C primary reactant system, the temperature field of the coupled reaction can be optimized. This approach aims to simultaneously achieve the synthesis of ultrafine SiC nanoparticles and high-purity Si<sub>3</sub>N<sub>4</sub> powders, thereby offering a novel route for the rapid and cost-effective production of advanced SiC and Si<sub>3</sub>N<sub>4</sub> ceramic powders.

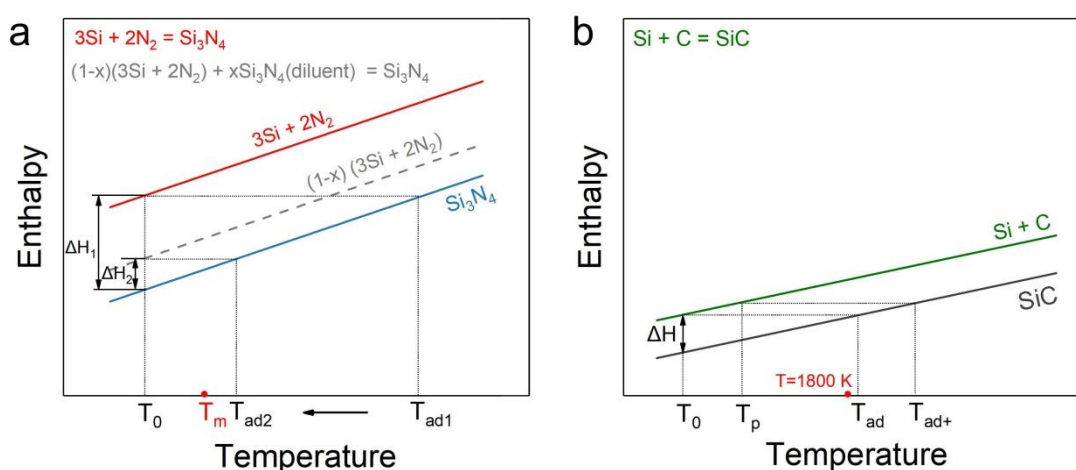
## 2. Results and discussion

### 2.1 Thermodynamic considerations

It is well established that Si<sub>3</sub>N<sub>4</sub> powders can be synthesized from Si powder via combustion synthesis under high-pressure nitrogen gas. This reaction is highly exothermic, and its adiabatic combustion temperature ( $T_{ad1}$ ) significantly exceeds the melting point of silicon ( $T_m = 1410 \text{ }^\circ\text{C}$ ). In



order to prevent the melting of Si, which would otherwise reduce the nitridation efficiency, up to 50 ~ 60 wt% of  $\text{Si}_3\text{N}_4$  is typically added as a diluent during the reaction process.<sup>24,28</sup> This addition reduces the adiabatic combustion temperature to a lower level ( $T_{\text{ad}2}$ ), slightly above the melting point of Si (Fig. 1a). However, this approach comes at the cost of a reduced net yield due to the large amount of diluent required. Additionally, for the system of the Si-C reaction, which is weakly exothermic, as demonstrated in Fig. 1b, the adiabatic temperature can be elevated (from  $T_{\text{ad}}$  to  $T_{\text{ad}+}$ ) by increasing the initial temperature of the system.<sup>22</sup> This provides the necessary thermal condition to sustain the propagation of the combustion wave in the Si-C system. Nevertheless, such preheating-based strategies inevitably result in prolonged exposure to elevated temperatures, which leads to severe grain coarsening and hinders the formation of nanoscale powders.<sup>29</sup>



**Fig. 1** Schematic illustration of the thermodynamic principles for regulating the adiabatic combustion temperature ( $T_{\text{ad}}$ ) in the Si-C and Si- $\text{N}_2$  combustion synthesis systems. (a) Si- $\text{N}_2$  system; (b) Si-C system.

In this work, a novel chemical furnace-assisted combustion synthesis approach is proposed for the synthesis of both types of single-phase ceramic powders. In this approach, the Si-C and Si- $\text{N}_2$  reaction systems are coupled through a rational powder configuration to synthesize nanoscale SiC powders. During the preheating of the Si-C system by the highly exothermic Si- $\text{N}_2$  reaction, the Si/C primary reactant, which is characterized by a high infrared absorption both before and after the reaction, effectively absorbs the radiative heat released from the Si- $\text{N}_2$  reaction, acting as a highly efficient thermal sink. By strategically utilizing this enhanced heat transfer effect, the temperature of the Si-C system can be rapidly elevated to promote its reaction, while simultaneously suppressing



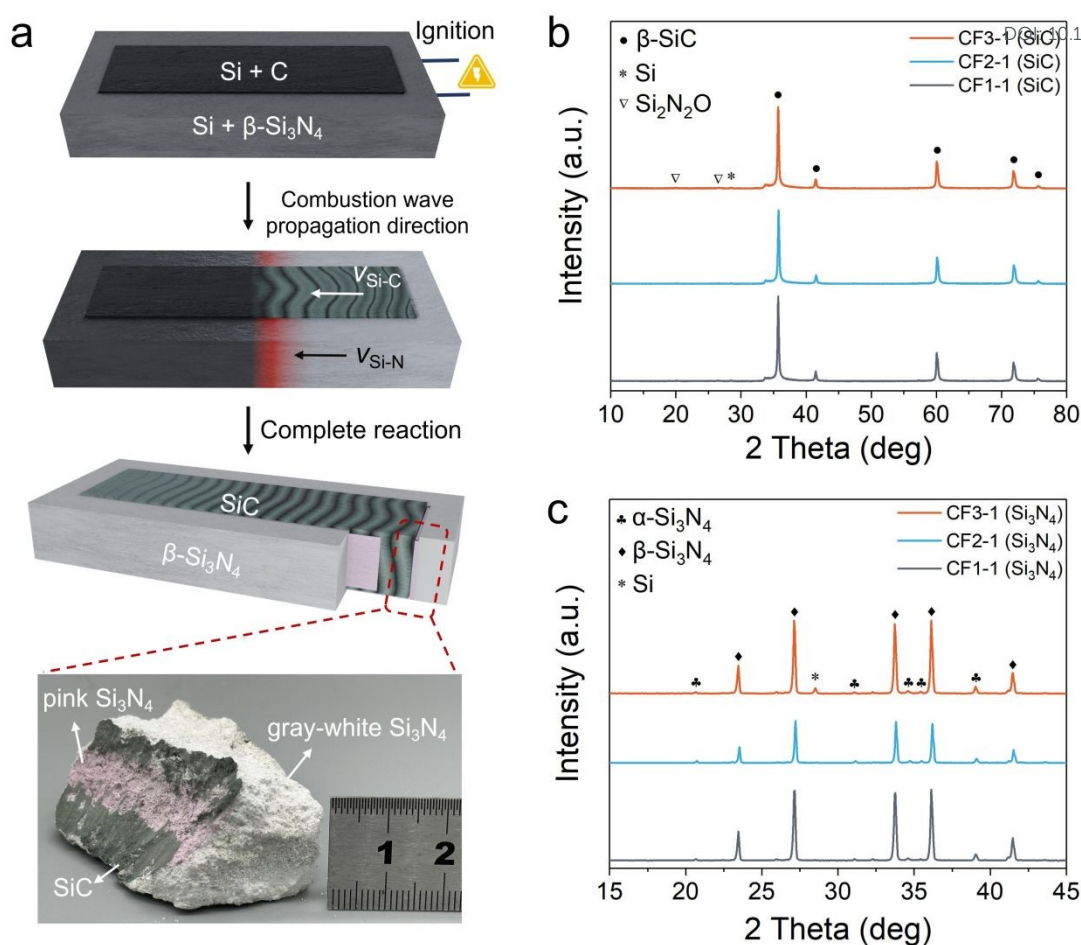
excessive overheating in the Si-N<sub>2</sub> system. This also enables a reduction in the amount of diluent required in the Si/Si<sub>3</sub>N<sub>4</sub> mixture. Thermodynamic calculations reveal that the energy released from the Si-N<sub>2</sub> reaction (~4381 kJ kg<sup>-1</sup>) vastly exceeds the energy required to ignite the Si/C mixture (~1595 kJ kg<sup>-1</sup>) by a factor of 2.7 (Supplementary Note 1). This significant surplus confirms that the Si-N<sub>2</sub> reaction provides ample energy to both initiate and sustain the self-propagating combustion process. Based on the above thermodynamic considerations, this study aims to regulate the temperature field of the Si-C combustion synthesis by adjusting the ratio between the Si-N<sub>2</sub>-based chemical furnace and the Si/C primary reactant system.

## 2.2 Combustion synthesis and phase formation

The combustion synthesis process for preparing nano-sized SiC assisted by a Si-N<sub>2</sub> chemical furnace is illustrated in Fig. 2a. The heat released from the surrounding Si-N<sub>2</sub> chemical furnace reaction serves to preheat the enclosed Si/C powder mixture. The high temperature at the combustion front of the furnace also provides effective ignition for the Si/C reactants, thereby initiating a self-propagating combustion synthesis reaction. Upon completion of the reaction, green SiC products were obtained in the central region of the crucible, while the peripheral region yielded gray-white Si<sub>3</sub>N<sub>4</sub> products. Notably, a millimeter-thick pink Si<sub>3</sub>N<sub>4</sub> interfacial layer was clearly observed at the boundary between the SiC and Si<sub>3</sub>N<sub>4</sub> products.

As demonstrated in Fig. 2b, under three distinct chemical furnace conditions with varying Si/Si<sub>3</sub>N<sub>4</sub> ratios, the combustion-synthesized products from the Si-C system all exhibited  $\beta$ -SiC as the predominant phase, with a phase content exceeding 99.7 wt%. The minor secondary phases included unreacted residual Si and a trace amount of Si<sub>2</sub>N<sub>2</sub>O, with the oxygen likely originating from the Si powder itself.<sup>30</sup> In contrast, the reaction products from the three chemical furnace formulations were primarily composed of  $\beta$ -Si<sub>3</sub>N<sub>4</sub>, accompanied by a small amount of  $\alpha$ -Si<sub>3</sub>N<sub>4</sub> (Fig. 2c). As is well established,  $\beta$ -Si<sub>3</sub>N<sub>4</sub> is the thermodynamically stable phase at high temperatures in comparison with  $\alpha$ -Si<sub>3</sub>N<sub>4</sub>. Consequently, the formation of abundant  $\beta$ -Si<sub>3</sub>N<sub>4</sub> indicates that all three furnace systems generated sufficiently high temperatures suitable for triggering the combustion synthesis of the Si-C system.



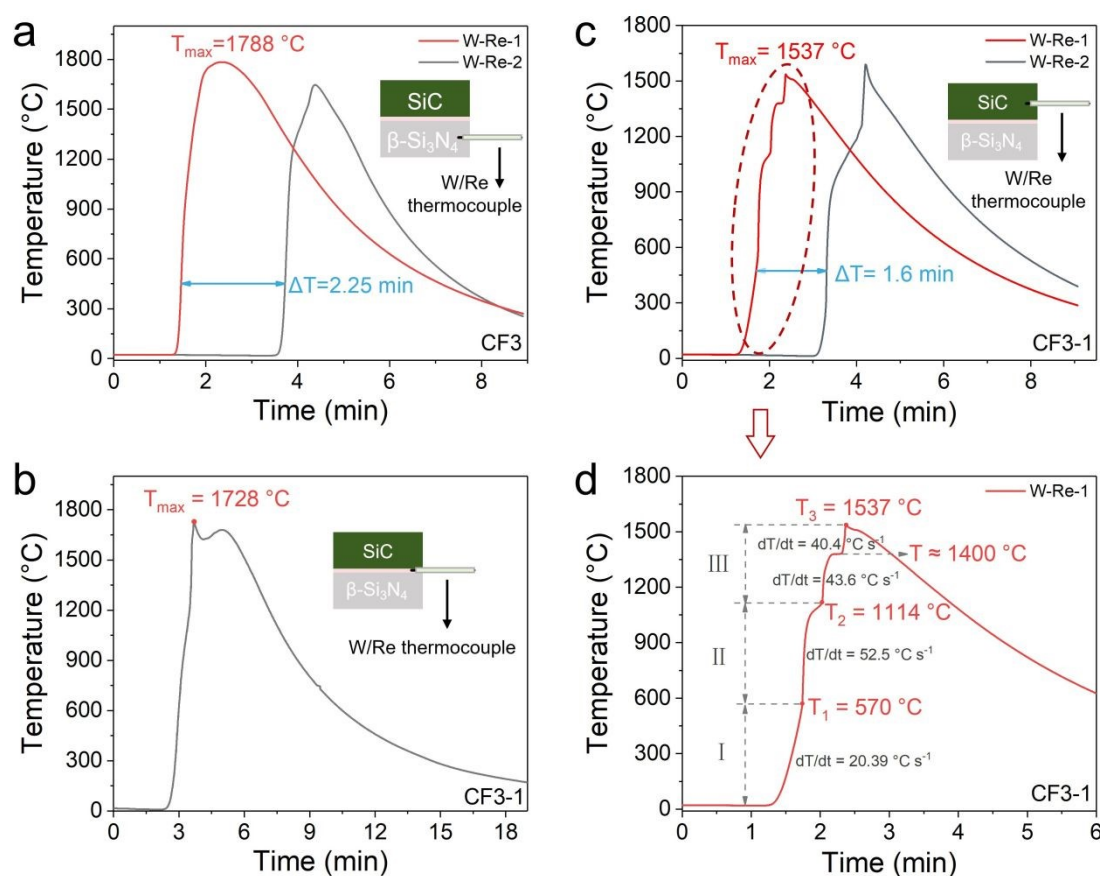


**Fig. 2** Reaction mechanism and phase composition of SiC synthesized via Si-N<sub>2</sub> chemical furnace-assisted combustion. (a) Schematic illustration of the surrounding chemical furnace-assisted combustion configuration and combustion wave propagation; (b) XRD patterns of the combustion-synthesized product at the central region (primary reaction zone); (c) XRD patterns of the product at the peripheral region (chemical furnace zone).

As illustrated in Fig. 3a-c, the temperature-time profiles were recorded at three different locations during the chemical furnace-assisted combustion synthesis of SiC. The positions of the W/Re thermocouples are indicated in the insets. In the Si-N<sub>2</sub> reaction system, which serves as the chemical furnace, the peak reaction temperatures ranged from 1660 to 1788 °C by adjusting the content of the Si<sub>3</sub>N<sub>4</sub> diluent (CF1, CF2, and CF3; Fig. S1 and Table S1). At the interface between the Si-N<sub>2</sub> and Si-C reaction zones, the reaction temperature reached up to 1728 °C. Conversely, the maximum temperature within the Si-C reaction zone exhibited a comparatively lower range, varying from 1086 to 1537 °C (Fig. S2). The results obtained demonstrate a rapid radial temperature



decrease from the outer Si-N<sub>2</sub> system toward the center. Nevertheless, the combustion wave propagation velocities of the Si-N<sub>2</sub> and Si-C reaction systems were comparable:  $V_{\text{Si-N}} = 16\sim 25 \text{ mm min}^{-1}$  and  $V_{\text{Si-C}} = 17\sim 25 \text{ mm min}^{-1}$ , respectively. This finding suggests that the combustion wave in the Si-N<sub>2</sub> system effectively initiates and synchronizes the combustion synthesis of the Si-C system. Table 1 provides a synopsis of the combustion wave velocity, peak reaction temperature, and product phase composition of the Si-C system under varying chemical furnace-assisted conditions. It is noteworthy that the Si-C system exhibits characteristics of oscillatory combustion during the synthesis process (Supplementary Notes 2-3). In particular, when a chemical furnace with a high diluent content is utilized (e.g., CF1 with 50 wt%), the Si-C reaction tends to be incomplete.



**Fig. 3** Temperature-time (T-t) profiles of the Si-N<sub>2</sub> reaction system, the Si-C reaction system, and their interface during chemical furnace-assisted combustion synthesis. (a) T-t curve of the CF3 chemical furnace system during the reaction process; (b) T-t curve at the interface between the Si-C and Si-N<sub>2</sub> systems in the CF3-1 reaction configuration; (c) T-t curve of the Si-C reaction in the CF3-1 system; (d) Enlarged view of the T-t curve during the Si-C reaction in the CF3-1 system.

Using the CF3-1 reaction system as a representative example, Fig. 3d presents a magnified



view of the T-t curve for the Si-C region within the CF3-1 chemical furnace-assisted system, with three inflection points along the heating curve marked, along with the corresponding heating rates. Based on this analysis: Stage I ( $T < \sim 600\text{ }^{\circ}\text{C}$ ) corresponds to the preheating of the Si-C system due to heat released from the outer chemical furnace. Stage II ( $\sim 570\text{--}1100\text{ }^{\circ}\text{C}$ ) is attributed to the exothermic Si-N<sub>2</sub> reaction. This reaction occurs at such a relatively low temperature due to the nitridation of Si vapor diffusing from the chemical furnace into the Si-C region.<sup>31</sup> The heat released by this vapor-phase Si-N<sub>2</sub> reaction further initiates additional nitridation reactions with the residual raw materials in the Si-C region, thereby accelerating the heating rate to approximately  $52.5\text{ }^{\circ}\text{C s}^{-1}$ . In Stage III ( $T > \sim 1100\text{ }^{\circ}\text{C}$ ), the temperature becomes sufficiently high to trigger the highly exothermic Si-C reaction,<sup>32,33</sup> which is the primary heat source at this stage. This reaction leads to an increase in temperature, which ultimately reaches  $1537\text{ }^{\circ}\text{C}$ . The observation of a temperature plateau near  $1400\text{ }^{\circ}\text{C}$  can be attributed to the endothermic melting of Si powder.

According to the thermal profile, the critical ignition temperature ( $T_i$ ) for the combustion synthesis of SiC in this system is estimated to be around  $1100\text{ }^{\circ}\text{C}$ , which is approximately  $100\text{ }^{\circ}\text{C}$  lower than the value reported by Wang et al. for radio-frequency-heated SiC combustion synthesis under an Ar atmosphere ( $T_i \approx 1200\text{ }^{\circ}\text{C}$ ).<sup>34</sup> This reduction in  $T_i$  is likely due to the increased reactivity of the Si reagent, which originates from two primary factors: (1) the diffusion of reactive gaseous Si generated under the strong exothermic conditions of the chemical furnace, and (2) the high-temperature decomposition of newly formed Si<sub>3</sub>N<sub>4</sub> in the presence of coexisting carbon in this region, which further releases highly reactive Si vapor.<sup>35,36</sup> Additionally, at approximately  $2100\text{ K}$ , the Si vapor pressure over the Si/Si<sub>3</sub>N<sub>4</sub> system ( $\approx 4 \times 10^{-1}\text{ Pa}$ ) exceeds that over the Si/SiC system ( $\approx 3 \times 10^{-2}\text{ Pa}$ ) by an order of magnitude, and this disparity in Si vapor pressure between Si<sub>3</sub>N<sub>4</sub> and SiC further biases the reaction toward SiC formation under non-equilibrium conditions.<sup>30</sup>



**Table 1** Propagation velocity of combustion wave, peak reaction temperature, and product phase composition of the Si-C system under different chemical furnace-assisted conditions. View Article Online  
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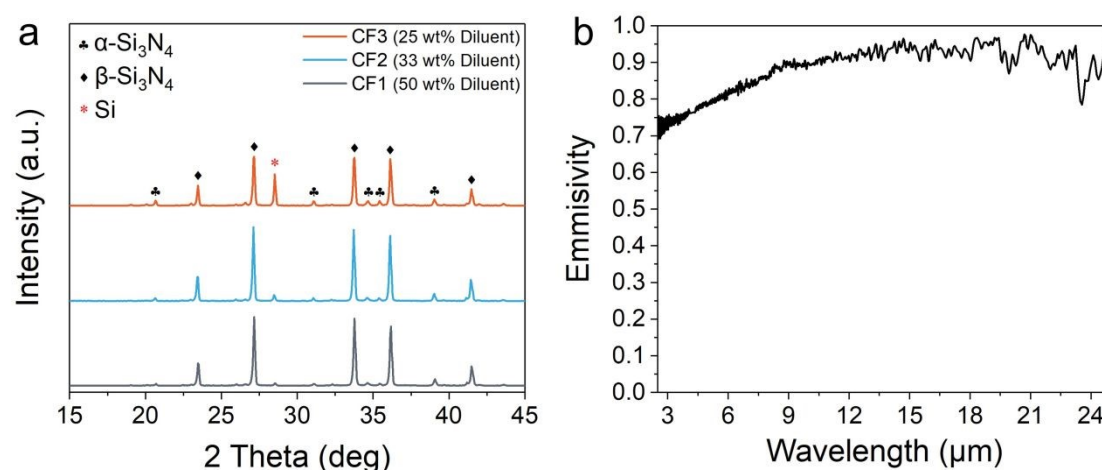
Reaction systems	$V$ (mm min <sup>-1</sup> )	$T_{\max}$ (°C)	$\beta$ -SiC (wt%)	Impurities
CF1-1	17.1	1086	99.8	Si, Si <sub>2</sub> N <sub>2</sub> O
CF2-1	18.9	1334	99.7	Si, Si <sub>2</sub> N <sub>2</sub> O
CF3-1	25.4	1537	99.8	Si, Si <sub>2</sub> N <sub>2</sub> O
CF3-2	13.6	956	/	/
CF3-3	13.6	787	/	/

To determine the minimum required amount of chemical furnace material capable of driving the weakly exothermic Si-C reaction, the effect of varying the mass ratio between the chemical furnace reactants and the primary reactants (i.e.,  $W_{\text{Si/Si}_3\text{N}_4} : W_{\text{Si/C}}$ ) was investigated based on the CF3 chemical furnace system. The results indicated that when the ratio was reduced from 3:1 to 1:1, the combustion wave in the Si-C system was unable to propagate over a significant distance, and SiC formation occurred exclusively in the proximity of the ignition source. The maximum temperature in the reacted region, as measured by thermocouples, was found to be below 1000 °C (Fig. S3). This observation highlights that the temperature field within the Si-C primary reactant system can be flexibly and conveniently tuned by adjusting the mass ratio between the chemical furnace and the primary reactants. Experimental results indicated that a mass ratio of  $W_{\text{Si/Si}_3\text{N}_4} : W_{\text{Si/C}} = 3:1$  is optimal, as it ensures that the synthesized SiC experiences a sufficiently high temperature and thermal holding time, resulting in well-dispersed nanoscale SiC powders.

Interestingly, when the chemical furnace-assisted combustion synthesis of SiC was performed, the Si-N<sub>2</sub> system—serving as the chemical furnace—exhibited markedly different behavior compared to when it underwent combustion synthesis independently. As shown in Fig. 4a, the residual Si content in the product of the standalone CF3 furnace was 10.4 wt%. However, when the same CF3 system was used as a chemical furnace to assist SiC synthesis (CF3-1), the residual Si content in the chemical furnace product was significantly reduced to only 1.66 wt%, representing an 84% decrease. A similar trend was observed across other chemical furnace systems with varying diluent contents. Each coupled system exhibited reduced residual Si content in the furnace product. Detailed comparisons of phase compositions are provided in Table S2.



These results demonstrate that the residual Si issue induced by melting during the combustion synthesis of the Si-N<sub>2</sub> system can be substantially mitigated via coupling it with the Si-C system. This improvement is attributed to thermal radiation transfer from the combustion wave zone to the Si-C primary reactant. As illustrated in Fig. 4b, the Si/C powder mixture exhibits a high radiative absorptivity, with an infrared emissivity of approximately 0.9. In accordance with the Stefan-Boltzmann law,<sup>37</sup> the radiant energy emitted by a blackbody increases sharply with rising temperature. The Si/C primary reactant functions as an efficient absorber of this radiative heat, which facilitates the rapid dissipation of heat from the combustion wave zone (the region where Si<sub>3</sub>N<sub>4</sub> is formed). Consequently, the primary reactant plays a crucial role in modulating the temperature field of the chemical furnace system. By appropriately harnessing this thermal regulation effect, the synchronous and synergistic combustion synthesis of the Si-N<sub>2</sub> and Si-C systems can be effectively realized.



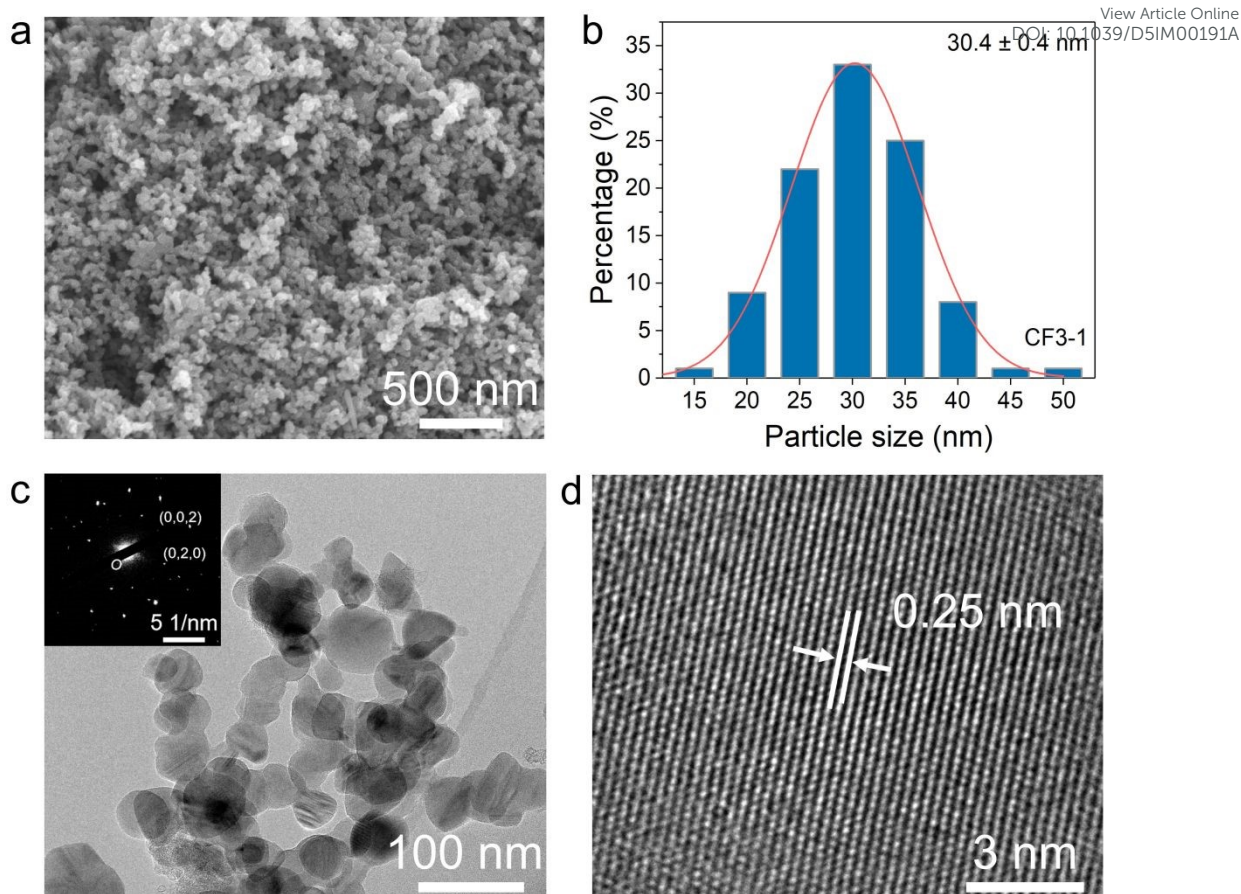
**Fig. 4** Phase composition of products from three Si-N<sub>2</sub> chemical furnace systems and spectral emissivity of the Si/C reactant. (a) XRD patterns of the products obtained from independently reacted chemical furnace systems with varying diluent contents; (b) Infrared emissivity spectrum of the Si/C reactant.

### 2.3 Microstructure of nano SiC

SEM observation of the nano-SiC powders synthesized via the CF3-1 chemical furnace-assisted combustion revealed that the powders consist of large aggregates of nano-sized SiC particles. After mild ultrasonic dispersion, the aggregates exhibited a  $D_{50}$  of ~780 nm (Fig. S4). This submicron-scale aggregation is acceptable for slurry preparation and coating, and can be further reduced by



milling to ensure uniformity in subsequent processing. As shown in Fig. 5a, the SiC particles are uniformly distributed across the entire field of view and exhibit equiaxed crystal morphology. The particle size statistics shown in Fig. 5b indicate that the average diameter of the SiC nanoparticles is approximately 30 nm, which is superior to that achieved by the preheating method ( $\sim 130$  nm),<sup>17</sup> and the electric field-assisted method (on the micrometer scale),<sup>38</sup> and is comparable to those produced by CVD,<sup>39</sup> and carbothermal reduction methods,<sup>40</sup> while requiring neither complex equipment nor prolonged reaction time (Table S3). Similar particle size and morphological characteristics were observed for the products synthesized in CF1-1 and CF2-1 systems (Fig. S5). A comparison between the raw carbon black and the synthesized SiC particles revealed that the SiC nanoparticles retained the morphology of the carbon black precursor (Fig. 5c and Fig. S6). Selected area electron diffraction (SAED) further confirmed the face-centered cubic (FCC) structure of the SiC nanoparticles. As shown in Fig. 5d, high-resolution TEM (HRTEM) images revealed an interplanar spacing of  $\sim 0.25$  nm, corresponding to the (111) plane of  $\beta$ -SiC.<sup>41</sup> Stacking faults (SFs) observed in the SiC nanoparticles (Fig. S7) are likely attributed to the non-equilibrium nature of the combustion synthesis process, characterized by high temperatures and rapid heating/cooling rates.<sup>42</sup> Energy-dispersive X-ray spectroscopy (EDS) analysis indicated that a small amount of oxygen is distributed on the surface of the SiC nanoparticles (Fig. S8). In summary, the primary phase of the synthesized nanoparticles is  $\beta$ -SiC. Minor impurities, including residual Si,  $\text{Si}_2\text{N}_2\text{O}$ , and surface oxygen, were also detected. The nitrogen content was determined to be  $\sim 2.1$  wt% by oxygen-nitrogen analysis.



**Fig. 5** Microstructure and structural characterization of nano-SiC synthesized via chemical furnace-assisted combustion. (a) SEM image of the combustion-synthesized SiC nanoparticles; (b) Statistical particle size distribution of the SiC nanoparticles; (c) TEM image of the SiC nanoparticles, the inset shows the SAED pattern of SiC; (d) HR-TEM image of the SiC nanoparticles.

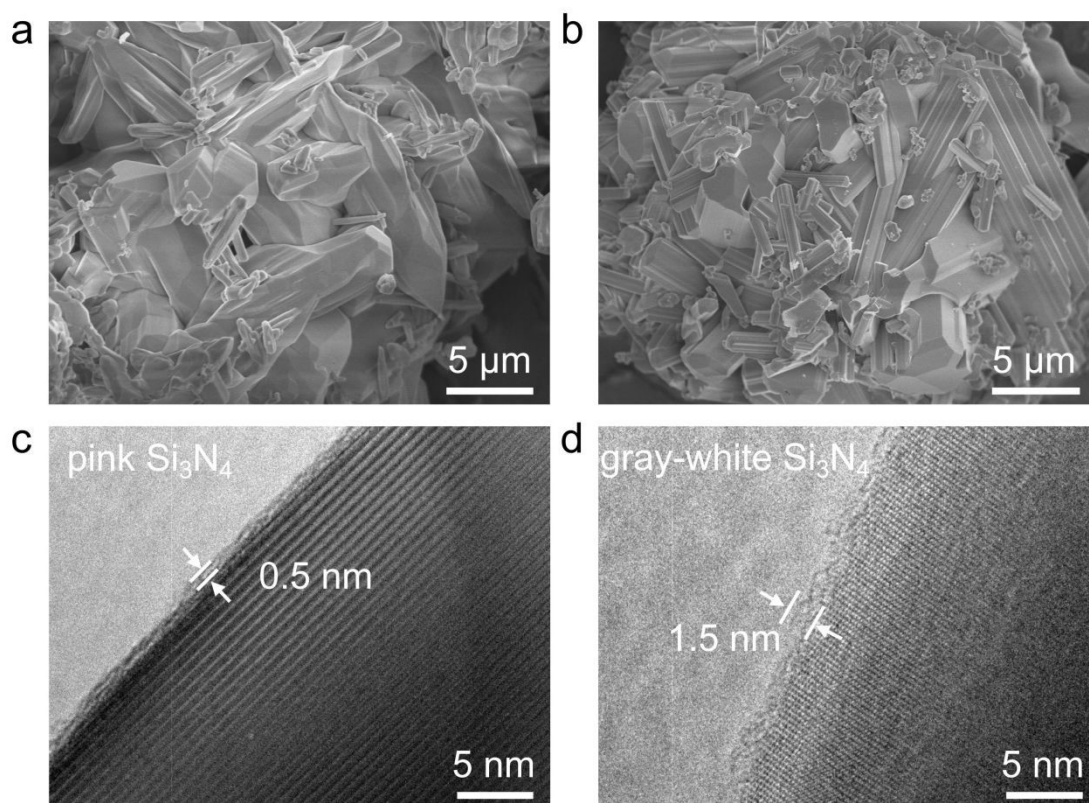
#### 2.4 Microstructural and spectroscopic analysis of pink $\beta$ -Si<sub>3</sub>N<sub>4</sub> in the chemical furnace system

As previously mentioned, a layer of pink Si<sub>3</sub>N<sub>4</sub> powder was observed on the Si<sub>3</sub>N<sub>4</sub> product side at the interface between the chemical furnace and the primary reaction product. SEM observations of the two differently colored Si<sub>3</sub>N<sub>4</sub> powders revealed that the gray-white Si<sub>3</sub>N<sub>4</sub> exhibits a more well-developed columnar grain structure, which is characteristic of  $\beta$ -Si<sub>3</sub>N<sub>4</sub> (Fig. 6a-b).<sup>43</sup> This difference in microstructure is likely related to the reaction temperature. The pink Si<sub>3</sub>N<sub>4</sub>, being adjacent to the Si-C mixed powder, experienced a lower crystal growth temperature, resulting in an underdeveloped columnar morphology. Statistical analysis of particle sizes further indicated that the pink Si<sub>3</sub>N<sub>4</sub> powder has an average particle size of approximately 4.6  $\mu$ m, while the gray-white Si<sub>3</sub>N<sub>4</sub> powder has a larger average size of about 3.3  $\mu$ m (Fig. S9). A comparative analysis of the phase composition



between the pink and the concurrently generated gray-white  $\text{Si}_3\text{N}_4$  powders showed that both consist mainly of  $\beta\text{-Si}_3\text{N}_4$  (Fig. S10 and Table S4). However, the pink  $\text{Si}_3\text{N}_4$  contains a lower amount of residual Si, indicating a higher phase purity.

It should be emphasized that the pink  $\beta\text{-Si}_3\text{N}_4$  obtained at the reaction interface exhibits a lower oxygen content compared to the gray-white  $\beta\text{-Si}_3\text{N}_4$ , with the results summarized in Table 2. Furthermore, comparison with the oxygen content of commercially available high-purity  $\text{Si}_3\text{N}_4$  powder from UBE Corporation (Japan) further confirms that the combustion-synthesized  $\text{Si}_3\text{N}_4$  possesses a lower oxygen concentration. This decrease in oxygen is directly correlated with the thinning of the amorphous  $\text{SiO}_2$  surface layer, as confirmed by the TEM observations that the amorphous oxide layer on the surface of the pink  $\text{Si}_3\text{N}_4$  is less than 1 nm thick, whereas the oxide layer on the gray-white  $\text{Si}_3\text{N}_4$  surface measures 1-2 nm in thickness (Fig. 6c-d).



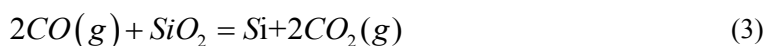
**Fig. 6** Microstructures of combustion-synthesized  $\text{Si}_3\text{N}_4$  products. (a) SEM image of pink  $\text{Si}_3\text{N}_4$ ; (b) SEM image of gray-white  $\text{Si}_3\text{N}_4$ ; (c) High-resolution TEM image of pink  $\text{Si}_3\text{N}_4$ ; (d) High-resolution TEM image of gray-white  $\text{Si}_3\text{N}_4$ .



**Table 2** Elemental composition analysis of different Si<sub>3</sub>N<sub>4</sub> samples.View Article Online  
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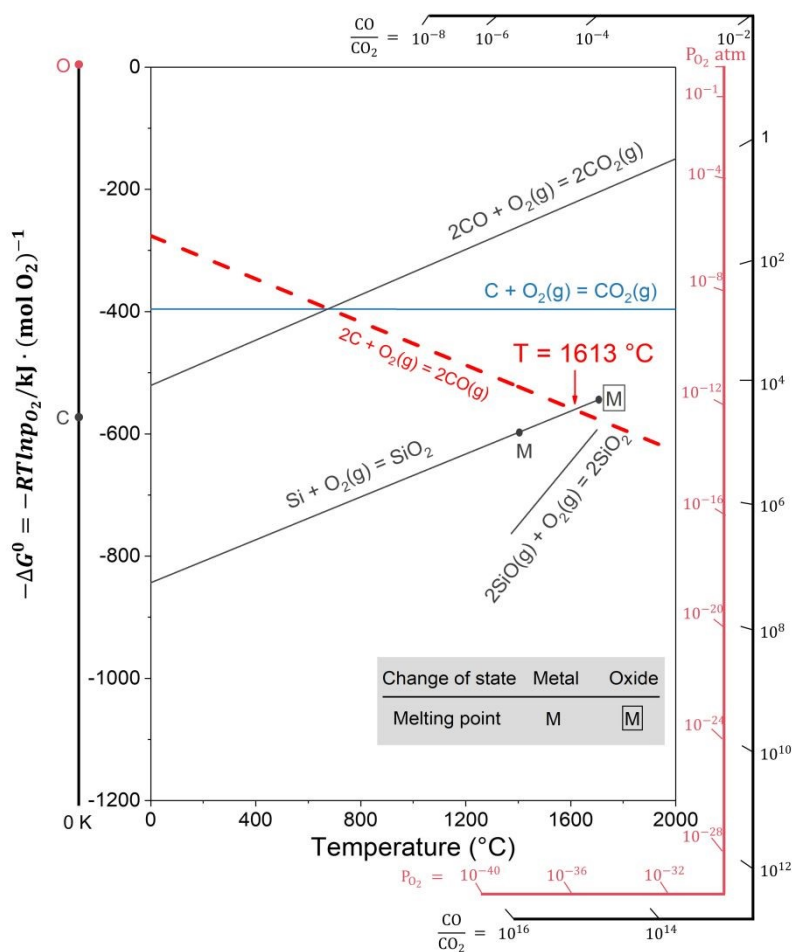
Samples	O (wt%)	N (wt%)	Al (ppm)	Ca (ppm)	Fe (ppm)
pink $\beta$ -Si <sub>3</sub> N <sub>4</sub>	0.46	32.22	72.70	9.52	22.08
gray-white $\beta$ -Si <sub>3</sub> N <sub>4</sub>	0.66	34.55	74.21	70.94	15.72
pink $\beta$ -Si <sub>3</sub> N <sub>4</sub> (after annealing)	0.61	34.94	/	/	/
$\beta$ -Si <sub>3</sub> N <sub>3</sub> (diluent)	3.01	38.07	600-700	<100	<100
Si <sub>3</sub> N <sub>4</sub> from UBE	1.20	38.33	<20	<30	<20

The ultralow oxygen content in the pink Si<sub>3</sub>N<sub>4</sub> powder can be explained based on the Ellingham diagram (Fig. 7).<sup>44</sup> According to the reaction system analysis, the most likely reaction to occur in the Si-C-O system is as follows:



According to the Ellingham diagram, SiO<sub>2</sub> is the thermodynamically stable phase below 1600 °C (reaction (1)). However, when the temperature exceeds 1612 °C, carbon from the Si-C reaction system is converted to CO via reaction (2). As shown by the temperature measurements in Fig. 3b, the interface between the Si-N<sub>2</sub> and Si-C systems reaches as high as 1728 °C, making reaction (3) inevitable, thereby creating a CO-rich, low equilibrium oxygen partial pressure reducing environment. Furthermore, according to the Ellingham analysis, at the interfacial temperature of 1728 °C, the oxygen partial pressure corresponding to the C/CO equilibrium is as low as approximately 10<sup>-14</sup> atm, which is significantly lower than that required for the Si/SiO<sub>2</sub> equilibrium (~10<sup>-12</sup> atm). Under these conditions, the SiO<sub>2</sub> layer present on the surface of Si<sub>3</sub>N<sub>4</sub> is reduced (reaction (3)), ultimately yielding high-purity Si<sub>3</sub>N<sub>4</sub> with low oxygen content. At the interface adjacent to the Si/C primary reactant, the proximity to the carbon source results in the highest CO concentration and thus the lowest oxygen content, which explains the formation of the pink Si<sub>3</sub>N<sub>4</sub> obtained.





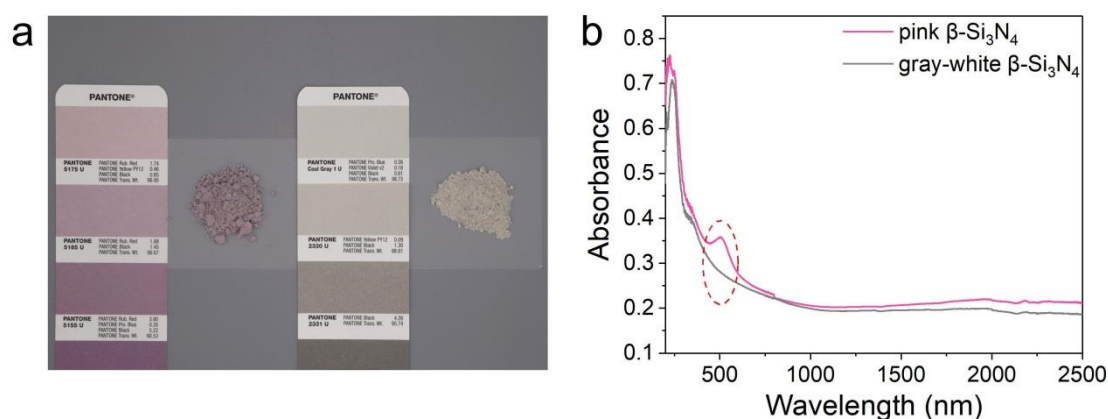
**Fig. 7** Thermodynamic analysis of the formation mechanism of high-purity, low-oxygen pink  $\beta$ - $\text{Si}_3\text{N}_4$  based on the Ellingham diagram (Si-O and C-O systems).

The comparison of  $\text{Si}_3\text{N}_4$  powders with different colors is shown in Fig. 8a. Interestingly, after high-temperature annealing treatment at  $600^\circ\text{C}$ , the pink  $\beta$ - $\text{Si}_3\text{N}_4$  turns gray-white again (Fig. S11). This phenomenon indicates that the surface of the pink  $\text{Si}_3\text{N}_4$  undergoes oxidation in high-temperature air, resulting in an increased thickness of the oxide layer. Therefore, while the oxygen content itself plays a role, its influence on color difference is essentially manifested through the modulation of the oxide layer thickness. This conclusion is further supported by the band gap ( $E_g$ ) measurements of  $\beta$ - $\text{Si}_3\text{N}_4$  powders of different colors. The absorption spectrum reveals that pink  $\text{Si}_3\text{N}_4$  exhibits a distinct absorption peak at a visible wavelength of 503 nm (Fig. 8b), consistent with the observed pink color. According to the Tauc plot method and using Eq. (4),<sup>45,46</sup> the band gap energy ( $E_g$ ) can be directly calculated from the UV-Vis-NIR spectral data.<sup>47</sup>



$$(\alpha h\nu)^{\frac{1}{n}} = C(h\nu - E_g) \quad (4)$$

Where  $\alpha$  is the absorption coefficient,  $h$  is the Planck constant,  $\nu$  is photon's frequency, and  $C$  is a constant. As shown in Fig. S12, the estimated  $E_g$  of pink  $\text{Si}_3\text{N}_4$  was calculated as 3.87 eV using Eq. (4), notably lower than that of gray-white  $\text{Si}_3\text{N}_4$  (4.15 eV). Since the  $E_g$  of  $\text{SiO}_2$  is larger than that of  $\text{Si}_3\text{N}_4$ , an increase in the thickness of the  $\text{SiO}_2$  layer leads to an overall increase in the material's band gap,<sup>48,49</sup> corresponding to the disappearance of the absorption peak at 503 nm and the loss of the pink color. Finally, a comparison of the oxygen and other metallic impurity contents in  $\beta\text{-Si}_3\text{N}_4$  and its diluents reveals that the  $\beta\text{-Si}_3\text{N}_4$  obtained after combustion synthesis is of higher purity, confirming that the combustion synthesis process has a purification effect on the final product.



**Fig. 8** Color comparison and absorption spectra of pink and gray-white  $\text{Si}_3\text{N}_4$  powders. (a) Optical photographs of the two synthesized powder samples compared with Pantone color swatches; (b) UV-Vis-NIR absorption spectra of pink and gray-white  $\text{Si}_3\text{N}_4$  powders.

The coupled reaction between the  $\text{Si-N}_2$  and  $\text{Si-C}$  systems not only enables efficient preheating and thermal field regulation of the weakly exothermic  $\text{Si-C}$  reaction via the strongly exothermic  $\text{Si-N}_2$  system, thereby facilitating the formation of nanoscale  $\text{SiC}$  at relatively low temperatures, but also benefits from the high infrared absorption of the  $\text{Si/C}$  powder. This high infrared absorptivity contributes to a reduction in the nitridation temperature and an enhancement in nitridation efficiency. Furthermore, the in-situ formation of a  $\text{CO}$ -rich and  $\text{O}_2$ -deficient reductive atmosphere creates favorable conditions for synthesizing high-purity, low-oxygen  $\text{Si}_3\text{N}_4$ . Consequently, this coupled reaction strategy realizes the simultaneous and synergistic combustion



synthesis of nano-SiC and pink, low-oxygen Si<sub>3</sub>N<sub>4</sub> ceramic powders.

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### 3. Conclusion

In this study, a coupled combustion synthesis approach was developed by combining a strongly exothermic Si-N<sub>2</sub> system, serving as a chemical furnace, with a weakly exothermic Si-C system as the primary reactant. This strategy enabled the simultaneous and synergistic synthesis of nanoscale SiC and high-purity, low-oxygen, pink  $\beta$ -Si<sub>3</sub>N<sub>4</sub> powders.

Thermodynamic analysis of the Si-C-N-O system revealed the formation mechanisms of the ultrafine SiC and pink  $\beta$ -Si<sub>3</sub>N<sub>4</sub>. The formation of nanoscale SiC was ascribed to the precise regulation of the high-temperature synthesis process. Specifically, the intense exothermic heat release from the Si-N<sub>2</sub> reaction provided the requisite energy input to initiate the combustion synthesis of the weakly exothermic Si-C system. This not only overcame the challenge of the Si-C system's limited self-propagation ability but also capitalized on the transient high-temperature environment induced by the Si-C reaction. Such a transient condition effectively avoids prolonged exposure of reactants to high temperatures, suppresses the grain growth of SiC, and ultimately yields SiC particles with an average primary particle size of approximately 30 nm. This method of generating a transient high-temperature field through the coupling of strong and weak exothermic reactions offers a promising route for the rapid and large-scale fabrication of high-quality nanoscale SiC powders.

The formation of pink, low-oxygen  $\beta$ -Si<sub>3</sub>N<sub>4</sub> powder is ascribed to the preferential reaction of residual oxygen in the system and surrounding environment with carbon in the high-temperature combustion wave zone, resulting in the generation of CO. This reaction consequently establishes a localized, oxygen-deficient, and CO-enriched reductive atmosphere at the interface of the Si-N<sub>2</sub> chemical furnace system. Such a reductive environment significantly decreases the oxygen content in the synthesized Si<sub>3</sub>N<sub>4</sub> at elevated temperatures. The resultant Si<sub>3</sub>N<sub>4</sub> exhibits a distinct pink hue and an ultra-low oxygen content of merely 0.46 wt%, representing a 60% reduction compared to the commercial high-purity Si<sub>3</sub>N<sub>4</sub> (1.20 wt%) supplied by UBE Corporation.

In summary, the proposed strategy of coupling strongly and weakly exothermic reactions enables a complementary reaction pathway for the simultaneous and synergistic synthesis of nanoscale SiC and high-purity, low-oxygen-content Si<sub>3</sub>N<sub>4</sub>. This work provides a novel and cost-



efficient route for the large-scale fabrication of high-quality SiC and Si<sub>3</sub>N<sub>4</sub> ceramic powders. [View Article Online  
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Nevertheless, the scalability of this approach may be limited by temperature gradients affecting product uniformity, and some yield loss is inevitable at the product interface; further optimization will be required to ensure reproducibility and industrial feasibility.

## 4. Experimental section

### 4.1. Material

The Si powder (purity:  $\geq 99.999\%$ ,  $D_{50} = 3 \mu\text{m}$ ) was purchased from Fujian Yitian Silicon Industry Co., Ltd. The  $\beta$ -Si<sub>3</sub>N<sub>4</sub> powder (purity:  $\geq 99.9\%$ ,  $D_{50} = 1.5 \mu\text{m}$ ) was obtained from Zhongke Xinci (Chongqing) Technology Co., Ltd. The carbon black (purity:  $\geq 99.9\%$ ,  $D_{50} = 28 \text{ nm}$ ) was supplied by Shanghai Fluorochem Technology Co., Ltd.

### 4.2. Material preparations

The combustion synthesis was carried out using a surrounding chemical furnace configuration, in which a Si/Si<sub>3</sub>N<sub>4</sub> powder mixture served as the chemical furnace reagent, while a Si/C powder mixture acted as the primary reactant. The Si/Si<sub>3</sub>N<sub>4</sub> mixture was placed around the Si/C powder in a ring-shaped layout. Specifically, the Si/C primary reactant is placed at the center, while the Si/Si<sub>3</sub>N<sub>4</sub> chemical furnace reagent is arranged around it. Three different mass ratios of Si to  $\beta$ -Si<sub>3</sub>N<sub>4</sub> (i.e.,  $W_{\text{Si}} : W_{\text{Si}_3\text{N}_4}$ ) were prepared for the chemical furnace material: 1:1, 2:1, and 3:1, denoted as CF1, CF2, and CF3, respectively. Specifically, Si powder and  $\beta$ -Si<sub>3</sub>N<sub>4</sub> powder (used as the diluent) were weighed according to the designed ratios and ball-milled for 0.5 h to obtain the chemical furnace mixture. For the primary reactant, Si powder and carbon black were mixed at a molar ratio of 1:1, with ethanol used as the milling medium. The mixture was then ball-milled at 360 rpm for 4 h using a planetary ball mill to obtain the Si/C composite powder. In the surrounding configuration, a defined mass of the Si/Si<sub>3</sub>N<sub>4</sub> furnace material was uniformly arranged around the Si/C powder. The mass ratio between the chemical furnace reagent and the primary reactant ( $W_{\text{Si/Si}_3\text{N}_4} : W_{\text{Si/C}}$ ) was varied among 3:1, 2:1, and 1:1. The detailed compositions and abbreviations of all reaction systems are summarized in Table 3.



**Table 3** Design of reaction systems for chemical furnace-assisted combustion synthesis. View Article Online  
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Reaction systems	Mass ratio	Mass ratio
	$W_{\text{Si}} : W_{\text{Si}_3\text{N}_4}$ (chemical furnace)	$W_{\text{Si/Si}_3\text{N}_4} : W_{\text{Si/C}}$
CF1-1	1:1	3:1
CF2-1	2:1	3:1
CF3-1	3:1	3:1
CF3-2	3:1	2:1
CF3-3	3:1	1:1

After loading, C-type W-Re5/26 thermocouples ( $\phi = 0.5 \text{ mm} \times 80 \text{ mm}$ ) were fixed at the designated measurement point and connected to a four-channel data acquisition system (the maximum acquisition rate is not less than 10 ms each time). The assembled reactants were then placed into a high-pressure reactor, evacuated, and filled with nitrogen gas at a pressure of 3 MPa. The combustion reaction was initiated by passing a 50 A current through a tungsten wire coil embedded in one end of the Si/Si<sub>3</sub>N<sub>4</sub> chemical furnace material to trigger the Si-N<sub>2</sub> reaction.

**4.3. Characterizations**

Microstructures of all samples were characterized by scanning electron microscopy (SEM; S-4800, Hitachi, Japan) and transmission electron microscopy (TEM; JEM F200, JEOL, Japan). Image analysis software (ImageJ) was used to measure the primary particle sizes over 100 particles in order to calculate the average sizes and size distributions. Phases were characterized by X-ray diffraction (XRD; D8 Focus, Bruker, Germany). The wave velocity ( $V$ ) was determined through the measurement of the distance between the two thermocouples and the time difference ( $\Delta t$ ) of the combustion wave passing through them. The particle size distributions of the SiC samples were analyzed by the particle size analyzer (Zetasizer nano ZSE, Malvern, United Kingdom). The particle size distributions of the Si<sub>3</sub>N<sub>4</sub> samples were analyzed by the laser particle size analyzer (Bettersize 2000E, Dandong Bettersize, China). Oxygen and nitrogen contents in the sample were measured by the oxygen-nitrogen analyzer (EMGA-820, HORIBA, Japan). Contents of iron, aluminum, and calcium in the sample were measured by an inductively coupled plasma optical emission



spectrometer (ICP-OES; 5800, Agilent, USA). The absorption intensities of the sample in the ultraviolet, visible, and near-infrared spectral ranges were measured by an ultraviolet-visible-near-infrared (UV-Vis-NIR) spectrometer (Cary 7000, Agilent, USA).

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### Data availability

The data supporting this article are available within the article and its ESI.† If necessary, the raw data are available upon request to the corresponding author (Prof. Yanhao Dong and Prof. Jiangtao Li).

### Conflicts of interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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### References

1. H. Tanaka, Silicon carbide powder and sintered materials, *J. Ceram. Soc. Jpn.*, 2011, **119**, 218–233.
2. Y. Wang, S. Dong, X. Li, C. Hong and X. Zhang, Synthesis, properties, and multifarious applications of SiC nanoparticles: A review, *Ceram. Int.*, 2022, **48**, 8882–8913.
3. S. Zhao, S. Du, S. Zhang, D. Zhao, B. Fan, B. Wang, F. Li, K. Chen and G. Liu, Low-temperature rapid sintering for the fabrication of biphasic Si<sub>3</sub>N<sub>4</sub> ceramics with outstanding mechanical properties, *J. Adv. Ceram.*, 2025, **14**, 9221044.
4. H. Li and J. Sun, Highly selective photocatalytic CO<sub>2</sub> reduction to CH<sub>4</sub> by ball-milled cubic silicon carbide nanoparticles under visible-light irradiation, *ACS Appl. Mater. Interfaces*, 2021, **13**, 5073–5078.
5. F. Nava, G. Bertuccio, A. Cavallini and E. Vittone, Silicon carbide and its use as a radiation detector material, *Meas. Sci. Technol.*, 2008, **19**, 102001.
6. R.A. Andrievski, Nano-sized silicon carbide: Synthesis, structure and properties, *Russ. Chem. Rev.*, 2009, **78**, 821–831.
7. Q. Qin, L. Han, G. Xiong, Z. Guo, J. Huang, Y. Zhang and Z. Shen, Impact of sintering aid type and content on the mechanical properties of digital light processing 3D-printed Si<sub>3</sub>N<sub>4</sub> ceramics, *Materials*, 2024, **17**, 5830.



8. M. Kitayama, K. Hirao, A. Tsuge, K. Watari, M. Toriyama and S. Kanzaki, Thermal conductivity of  $\beta$ - $\text{Si}_3\text{N}_4$ : II, Effect of lattice oxygen, *J. Am. Ceram. Soc.*, 2000, **83**, 1985–1992.
9. H. Shao, J. Qiu, X. Liu, X. Hou and J. Zhang, The temperature-dependent thermal conductivity of C- and O-doped  $\text{Si}_3\text{N}_4$ : First-principles calculations, *Crystals*, 2024, **14**, 549.
10. W. Zhang, An overview of the synthesis of silicon carbide-boron carbide composite powders, *Nanotechnol. Rev.*, 2023, **12**, 20220571.
11. Z. Huang, B. Liang, D. Jiang and S. Tan, Preparation of nanocrystal SiC powder by chemical vapour deposition, *J. Mater. Sci.*, 1996, **31**, 4327–4332.
12. Y. Lan, C. Yin, Y. Huang and L. Zhou, Synthesis of sub-micron spherical  $\alpha$ - $\text{Si}_3\text{N}_4$  powder by direct nitridation of silicon saw dust, *Silicon*, 2022, **14**, 475–479.
13. J. Narayan, R. Raghunathan, R. Chowdhury and K. Jagannadham, Mechanism of combustion synthesis of silicon carbide, *J. Appl. Phys.*, 1994, **75**, 7252–7257.
14. F. Li, J. Zhang, Y. Ge, K. Chen and G. Liu, Macro synthesis of SiC nanopowders via gas-phase reaction initiated by solid-phase reactants vaporizing in combustion synthesis, *J. Mater. Res. Technol.*, 2025, **35**, 5746–5754.
15. C. Agrafiotis, J. Lis, J. Puszynski and V. Hlavacek, Combustion synthesis of silicon nitride-silicon carbide composites, *J. Am. Ceram. Soc.*, 1990, **73**, 3514–3517.
16. S. Agathopoulos, Combustion synthesis of ultra-fine SiC powders in low pressure  $\text{N}_2$ -atmosphere, *Ceram. Int.*, 2012, **38**, 4165–4171.
17. R. Pampuch, L. Stobierski and J. Lis, Synthesis of sinterable beta-SiC powders by a solid combustion method, *J. Am. Ceram. Soc.*, 1989, **72**, 1434–1435.
18. G. Liu, K. Yang, J. Li, K. Yang, J. Du and X. Hou, Combustion synthesis of nanosized  $\beta$ -SiC powder on a large scale, *J. Phys. Chem. C*, 2008, **112**, 6285–6292.
19. A. Mukasyan, Y. Lin, A. Rogachev and D. Moskovskikh, Direct combustion synthesis of silicon carbide nanopowder from the elements, *J. Am. Ceram. Soc.*, 2013, **96**, 111–117.
20. A. Mukasyan, Combustion synthesis of silicon carbide, In: *Properties and Applications of Silicon Carbide*, edited by R. Gerhardt, InTech: Rijeka, Croatia, 2011, 389–409.
21. D. Moskovskikh, Y. Song, S. Rouvimov, A. Rogachev and A. Mukasyan, Silicon carbide ceramics: Mechanical activation, combustion and spark plasma sintering, *Ceram. Int.*, 2016, **42**, 12686–12693.
22. Y. Yang, K. Yang, Z. Lin and J. Li, Mechanical-activation-assisted combustion synthesis of SiC, *Mater. Lett.*, 2007, **61**, 671–676.
23. H. Jin, J. Li, M. Cao and S. Agathopoulos, Influence of mechanical activation on combustion synthesis of fine silicon carbide (SiC) powder, *Powder Technol.*, 2009, **196**, 229–232.
24. F. Li, W. Cui, Z. Tian, J. Zhang, S. Du, Z. Chen, S. Zhang, K. Chen and G. Liu, Effect of the diluent on combustion synthesis of silicon nitride, *Int. J. Appl. Ceram. Technol.*, 2022, **19**, 2957–2962.
25. L. Wang, G. He, X. Wu, Q. Meng, S. Deng, Z. Yang and J. Li, Effect of Si particle size and  $\text{NH}_4\text{Cl}$  additive on combustion synthesis of  $\alpha$ - $\text{Si}_3\text{N}_4$ , *Ceram. Int.*, 2019, **45**, 21635–21639.
26. J. Zhang, Y. Ge, Z. Tian, S. Sun, W. Cui, G. Liu and K. Chen, Combustion synthesis of  $\alpha$ - $\text{Si}_3\text{N}_4$  with green additives, *Ceram. Int.*, 2019, **45**, 6594–6596.
27. A. Mukasyan, Combustion synthesis of nitrides: Mechanistic studies, *Proc. Combust. Inst.*, 2005, **30**, 2529–2535.
28. I. Cano, I. Borovinskaya, M. Rodriguez and V. Grachev, Effect of dilution and porosity on

View Article Online  
DOI: 10.1039/D5IM00191A



- self-propagating high-temperature synthesis of silicon nitride, *J. Am. Ceram. Soc.*, 2002, **85**, 2209–2211. View Article Online  
DOI: 10.1059/D5IM00191A
29. J. Zeng, Y. Miyamoto and O. Yamada, Combustion synthesis of  $\text{Si}_3\text{N}_4$ -SiC composite powders, *J. Am. Ceram. Soc.*, 1991, **74**, 2197–2200.
  30. O. Yamada, K. Hirao, M. Koizumi and Y. Miyamoto, Combustion synthesis of silicon carbide in nitrogen atmosphere, *J. Am. Ceram. Soc.*, 1989, **72**, 1735–1738.
  31. R. Ghoshtagore and R. Coble, Self-diffusion in silicon carbide, *Phys. Rev.*, 1966, **143**, 623–626.
  32. V. Gorovenko, V. Knyazik and A. Shteinberg, High-temperature interaction between silicon and carbon, *Ceram. Int.*, 1993, **19**, 129–132.
  33. R. Pampuch, E. Walasek and J. Białoskórski, Reaction mechanism in carbon-liquid silicon systems at elevated temperatures, *Ceram. Int.*, 1986, **12**, 99–106.
  34. L. Wang, Y. Peng, X. Hu and X. Xu, Combustion synthesis of high purity SiC powder by radio-frequency heating, *Ceram. Int.*, 2013, **39**, 6867–6875.
  35. H. Wang and G.S. Fischman, In situ synthesis of silicon carbide whiskers from silicon nitride powders, *J. Am. Ceram. Soc.*, 1991, **74**, 1519–1522.
  36. G. Liu, K. Chen and J. Li, Combustion synthesis of carbide powders, In *Combustion Synthesis*, 2025, 299–346.
  37. A. Kolesnichenko, Thermodynamics of the Bose gas and blackbody radiation in non-extensive Tsallis statistics, *Sol. Syst. Res.*, 2020, **54**, 420–431.
  38. A. Feng and Z. Munir, The effect of an electric field on self-sustaining combustion synthesis: Part II. Field-assisted synthesis of  $\beta$ -SiC, *Metall. Mater. Trans. B*, 1995, **26B**, 587–593.
  39. Y. Kamlag, A. Goossens, I. Colbeck and J. Schoonman, Laser CVD of cubic SiC nanocrystals, *Appl. Surf. Sci.*, 2001, **184**, 118–122.
  40. M. Sharma, R. Upadhyay, S. Amritphale and N. Chandra, Synthesis of nano-structured 3C-SiC by carbothermal reduction of silicon bearing gel and carbon soot, *Mater. Lett.*, 2011, **65**, 2161–2164.
  41. L. Han, S. Chen, H. Li, Y. Dong, C. Wang and J. Li, Rapid and inexpensive synthesis of liter-scale SiC aerogels, *Nat. Commun.*, 2024, **15**, 6959.
  42. F. Li, W. Cui, Z. Tian, J. Zhang, S. Du, Z. Chen, K. Chen and G. Liu, Controlled growth of SiC crystals in combustion synthesis, *J. Am. Ceram. Soc.*, 2022, **105**, 44–49.
  43. S. Chen, L. Han, J. Li, Y. Dong and C. Wang, Rapid synthesis of high-strength porous  $\text{Si}_3\text{N}_4$  ceramics based on spontaneous solidification of multi-phase particles, *J. Am. Ceram. Soc.*, 2025, e20441.
  44. H. Ellingham, Reducibility of oxides and sulphides in metallurgical processes, *J. Chem. Technol. Biotechnol.*, 1944, **63**, 125–160.
  45. J. Tauc, R. Grigorovici and A. Vancu, Optical properties and electronic structure of amorphous germanium, *Phys. Stat. Sol.*, 1966, **15**, 627–637.
  46. P. Praus, O. Kozák, K. Kočí, A. Panáček and R. Dvorský, CdS nanoparticles deposited on montmorillonite: Preparation, characterization and application for photoreduction of carbon dioxide, *J. Colloid Interface Sci.*, 2011, **360**, 574–579.
  47. P. Jubu, O. Obaseki, A. Nathan-Abutu, F. Yam, Y. Yusof and M. Ochang, Dispensability of the conventional Tauc's plot for accurate bandgap determination from UV-Vis optical diffuse reflectance data, *Results Opt.*, 2022, **9**, 100273.



48. A. Tsaturyan, E. Kachan, R. Stoian and J. Colombier, Unraveling the electronic properties in  $\text{SiO}_2$  under ultrafast laser irradiation, *npj Comput. Mater.*, 2024, **10**, 200. [View Article Online](#)  
DOI: 10.1039/D5IM00191A
49. M. Sarki, I. Echi, A. Amah, I. Ahemen, K. Chan, U. Rilwan and M. Sayyed, Structural, electronic and optical properties of  $\alpha\text{-Si}_3\text{N}_4$ ,  $\beta\text{-Si}_3\text{N}_4$  and  $\gamma\text{-Si}_3\text{N}_4$  using density functional theory, *Next Research*, 2024, **1**, 100048.



### Data availability statement

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The data supporting this article are available within the article and its ESI.† If necessary, the raw data are available upon request to the corresponding author (Prof. Yanhao Dong and Prof. Jiangtao Li).

